



ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

November 18, 2025	
IGI Report Number	LG749589514
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	EMERALD CUT
Measurements	9.68 X 6.90 X 4.70 MM

GRADING RESULTS

Carat Weight	3.10 CARATS
Color Grade	E
Clarity Grade	VS 2

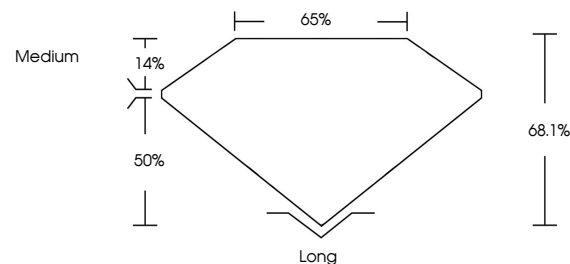
ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	 LG749589514

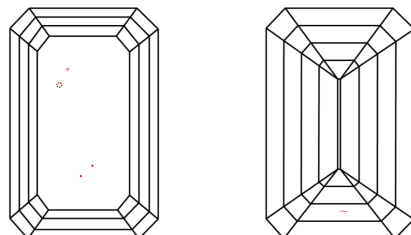
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

LG749589514
Report verification at igi.org

PROPORTIONS

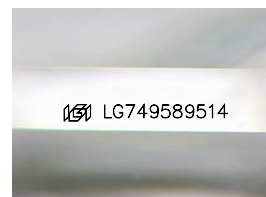


CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.



Sample Image Used

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

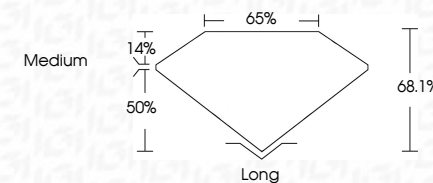
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November 18, 2025
GI Report No LG749589514

3.10 CARATS	VS 2	68.1%	65%	Medium	Long	EXCELLENT	EXCELLENT	NONE
Color Grade	Clarity Grade	Depth	Table	Girdle	Culet	Polish	Symmetry	Fluorescence

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